DERWENT-ACC-NO: 2002-463931

DERWENT-WEEK: 200249

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TITLE: Device for mask cleaning and manufacturing without

affecting the exposure body

INVENTOR: SHIRAISHI, N

PATENT-ASSIGNEE: NIKON CORP[NIKR]

PRIORITY-DATA: 2000JP-0391688 (December 22, 2000)

PATENT-FAMILY:

PUB-NO PUB-DATE LANGUAGE

PAGES MAIN-IPC

WO 200252345 July 4, 2002 J

035 G03F 001/08

Α1

DESIGNATED-STATES: AE AG AL AM AT AU AZ BA BB BG BR BY BZ CA CH CN CO CR CU CZ D

E DK DM DZ EC EE ES FI GB GD GE GH GM HR HU ID IL IN IS JP KE KG KP KR KZ LC LK

LR LS LT LU LV MA MD MG MK MN MW MX MZ NO NZ OM PH PL PT RO RU SD SE SG SI SK SL

TJ TM TR TT TZ UA UG US UZ VN YU ZA ZW AT BE CH CY DE DK EA ES FI FR GB GH GM G

R IE IT KE LS LU MC MW MZ NL OA PT SD SE SL SZ TR TZ UG ZM ZW

APPLICATION-DATA:

PUB-NO APPL-DESCRIPTOR APPL-NO

APPL-DATE

WO N/A 2001WO-JP11170

December 20, 2001

200252345A1

INT-CL (IPC): G03F001/08; G03F001/14; H01L021/027

ABSTRACTED-PUB-NO: WO 200252345A

BASIC-ABSTRACT: NOVELTY - A device for mask cleaning

0, 2001 200252345A1

INT-CL (IPC): G03F001/08; G03F001/14; H01L021/027

ABSTRACTED-PUB-NO: WO 200252345A BASIC-ABSTRACT: NOVELTY - A device for mask cleaning capable of efficiently cleaning reticle without affecting an exposure body part and transferring the cleaned reticle to the exposure body part without being contaminated; the method, comprising the steps of transferring the reticle (R) contained in a normal case (3) into a purge gas substitution chamber (24) to substitute the atmosphere around the reticle with a purge gas with high transmittance to exposure beam, performing an optical cleaning by the ultraviolet ray from an ultraviolet ray source (27), transferring the reticle (R) into a charging chamber (35) to load the reticle (R) air-tight into a clean case (8) in the purge gas atmosphere, and transferring the reticle (R) loaded in the clean case (8) to the exposure body part.

USE - Device for mask cleaning and manufacturing without affecting the exposure body

DESCRIPTION OF DRAWING(S) - Normal case 3

Gas substitution chamber 24

Ray source 27

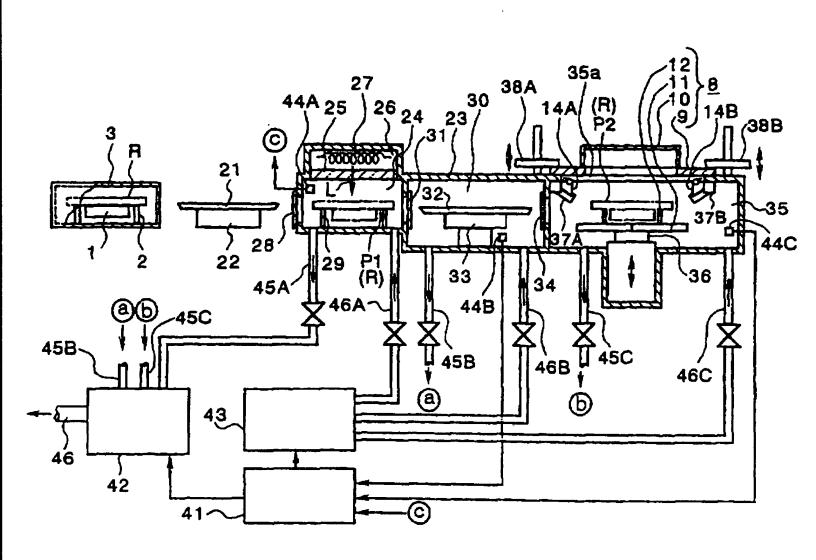
Reticle R

Charging chamber 35

Clean case 8

CHOSEN-DRAWING: Dwg.1/5

TITLE-TERMS:



	Туре	L #	Hits	Search Text	DBs	Time Stamp
1	IS&R	L1	1448	(250/492.2).CCLS.	USPAT; US-PGP UB	2002/10/25 14:47
2	IS&R	L2	0	(356/FOR "102").CCLS.	USPAT; US-PGP UB	2002/10/25 14:48
3	IS&R	L3	0	(356/FOR102).CCLS.	USPAT; US-PGP UB	2002/10/25 14:48
4	IS&R	L4	0	(356/FOR.102).CCLS.	USPAT; US-PGP UB	2002/10/25 14:48
5	IS&R	L5	440	(356/239.1,239.2,239.5,239. 6,239.8).CCLS.	USPAT; US-PGP UB	2002/10/25 14:49
6	BRS	L6	9	L1 and (optic\$3 near3 clean\$5)	USPAT; US-PGP UB	2002/10/25 14:52
7	BRS	L7	4	L5 and (optic\$3 near3 clean\$5)	USPAT; US-PGP UB	2002/10/25 14:56
8	BRS	L9	0	L7 and (purg\$5 near3 gas)	USPAT; US-PGP UB	2002/10/25 14:52
9	BRS	L8	1	L6 and (purg\$5 near3 gas)	USPAT; US-PGP UB	:/   //   //
10	BRS	L10	0	L7 and (maxim\$5 near3 concentration)	USPAT; US-PGP UB	2002/10/25 14:57
11	BRS	L11	0	L7 and (maxim\$5 near3 impurit\$4)	USPAT; US-PGP UB	2002/10/25 14:57
12	BRS	L12	0	L6 and (maxim\$5 near3 impurit\$4)	USPAT; US-PGP UB	2002/10/25 14:57
13	BRS	L15	2	(optic\$3 near3 clean\$4) and (purg\$4 near2 gas)		2002/10/25 15:17

10/25/2002, EAST Version: 1.03.0002

	Comments	Error Definition	Err ors
1			0
2			0
3			0
4			0
5			0
6			0
7			0
8			0
9			0
10			0
11			0
12			0
13			0

	Туре	L #	Hits	Search Text	DBs	Time Stamp
14	BRS	L16	62	(optic\$3 near3 clean\$4) and (purg\$4 near2 gas)	OD	2002/10/25 15:01
15	BRS	L14	2	(optic\$3 near3 clean\$4) and (purg\$4 near2 gas)	USOCR	2002/10/25 15:01
16	BRS	L13	6	(optic\$3 near3 clean\$4) and (purg\$4 near2 gas)		15:02

	Comments	Error Definition	Err ors
14			0
15		Truncation overflow.	1
16			0